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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/799,325	03/12/2004	Randy L. Hoffman	200315134-1	8192
22879 7.	590 02/08/2005		EXAM	INER
HEWLETT PACKARD COMPANY			TRAN, THIEN F	
P O BOX 272400, 3404 E. HARMONY ROAD INTELLECTUAL PROPERTY ADMINISTRATION			ART UNIT	PAPER NUMBER
FORT COLLINS, CO 80527-2400		2811		

DATE MAILED: 02/08/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

		ne ne				
	Application No.	Applicant(s)				
	10/799,325	HOFFMAN, RANDY L.				
Office Action Summary	Examiner	Art Unit				
	Thien F. Tran	2811				
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with t	he correspondence address				
A SHORTENED STATUTORY PERIOD FOR REPL THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a repl If NO period for reply is specified above, the maximum statutory period Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailin earned patent term adjustment. See 37 CFR 1.704(b).	I36(a). In no event, however, may a reply ly within the statutory minimum of thirty (30 will apply and will expire SIX (6) MONTHS a, cause the application to become ABAND	be timely filed i) days will be considered timely. from the mailing date of this communication. ONED (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on	_·					
·=						
	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
closed in accordance with the practice under E	Ex parte Quayle, 1935 C.D. 11	, 453 O.G. 213.				
Disposition of Claims						
4) ☐ Claim(s) 1-40 is/are pending in the application 4a) Of the above claim(s) is/are withdra 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) 1-40 are subject to restriction and/or	wn from consideration.					
Application Papers						
9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) acc Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Ex	cepted or b) objected to by to drawing(s) be held in abeyance. tion is required if the drawing(s) is	See 37 CFR 1.85(a). s objected to. See 37 CFR 1.121(d).				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority document 2. Certified copies of the priority document 3. Copies of the certified copies of the priority application from the International Burea * See the attached detailed Office action for a list	ts have been received. ts have been received in Appli rity documents have been rec u (PCT Rule 17.2(a)).	ication No eived in this National Stage				
Attachment(s)						
1) Notice of References Cited (PTO-892)	4) Interview Sumr					
 Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date 		ail Date nal Patent Application (PTO-152)				

DETAILED ACTION

Election/Restrictions

Restriction to one of the following inventions is required under 35 U.S.C. 121:

- Claims 1-14, 28-30 and 34-40, drawn to a semiconductor device, classified in class 257, subclass 411.
- II. Claims 15-27, drawn to process for making semiconductor devices, classified in class 438, subclass 22+.
- III. Claims 31-33, drawn to process for using semiconductor devices, classified in class 365, subclass 185.3+.

The inventions are distinct, each from the other because of the following reasons:

Inventions II and I are related as process of making and product made. The inventions are distinct if either or both of the following can be shown: (1) that the process as claimed can be used to make other and materially different product or (2) that the product as claimed can be made by another and materially different process (MPEP § 806.05(f)). In the instant case, unpatentability of the group I invention would not necessarily imply unpatentability of the method of the group II invention, since the device of the group I invention could be made by processes different from those of the group II invention. For example, instead of forming the drain electrode and the source electrode first, then depositing the channel contacting the drain electrode and the source electrode; forming the channel before forming the source electrode and the drain electrode.

function.

Inventions I and III are related as product and process of use. The inventions can be shown to be distinct if either or both of the following can be shown: (1) the process for using the product as claimed can be practiced with another materially different product or (2) the product as claimed can be used in a materially different process of using that product (MPEP § 806.05(h)). In the instant case, unpatentability of the group I invention would not necessarily imply unpatentability of the method of the group III invention, since the device of the group I invention could be used in processes of using that different from those of the group III invention. For example, the device could be used as a dummy device to help forming a global planarized dielectric layer above it in semiconductor device, wherein the device would not perform any operation

Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification, restriction for examination purposes as indicated is proper.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Thien F. Tran whose telephone number is (571) 272-1665. The examiner can normally be reached on 8:30AM - 5:00PM Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Eddie C. Lee can be reached on (571) 272-1732. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Application/Control Number: 10/799,325

Art Unit: 2811

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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February 2, 2005

THIENTRAN
PRIMARY EXAMINER

Mien Vmus

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